



Correction: Study on photoelectric characteristics of monolayer WS₂ films

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Correction for 'Study on photoelectric characteristics of monolayer WS₂ films' by Lin Wang *et al.*, *RSC Adv.*, 2019, 9, 37195–37200.

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The authors regret that the contact email address for the corresponding authors was incorrect in the original article. The correct email addresses are as shown here.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.



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